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U.S. Department of Commerce, Patent and Trademark		Atty. Docket No.	Application No.			
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		SNDK.352US0	10/799,060			
(Use several sheets if necessary)		Applicant(s)	Conf. No.			
(Form PTO-1449)		Jeffrey W. LUTZE et al.	6740			
		Filing Date	Art Group			
1 of 2		March 12, 2004	2818			
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*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
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Examiner	Dle	Date Considered	6/2006			
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.						

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		Document	Date	Country	Class	Subclass	Yes	No
Dle	7	EP 1274132 /	01/2003	EPO	—	—	<input checked="" type="checkbox"/>	<input type="checkbox"/>
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